Amendment to the Claims:

This listing of claims replaces all prior versions, and listings, of claims in the application:

1. (Previously presented) An FeRAM comprising:

a ferroelectric material sandwiched between a top electrode and a bottom electrode;

a V0-contact for providing an electrical connection with an underlying CS-contact, the V0-contact being formed in a hole and being aligned by the bottom electrode;

a liner layer covering a sidewall of the bottom electrode for providing a stop to an etch of the V0-contact hole; and

an alumina spacer deposited on the walls of the V0-contact hole following etching of the hole so that the alumina spacer extends over substantially the entire walls of the V0-contact hole.

2-7. (Canceled).

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